



Docket No.: 4425-090

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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

OCT-2-2003

In re Application of

TECHNOLOGY CENTER 2800

EXPEDITED PROCEDURE

Pei-Ren JENG

: ***RESPONSE UNDER 37 CFR 1.116***

U.S. Patent Application No. 09/729,833

: *Confirmation No. 5660*

Filed: December 6, 2000

: Group Art Unit: 2823

: Examiner: Hsien Lee

For: METHOD FOR PATTERNING A DUAL DAMASCENE WITH RETROGRADE
IMPLANTATION

REQUEST FOR RECONSIDERATION

Commissioner for Patents
P.O. Box 1450
Alexandria VA 22313-1450

Sir:

This paper is submitted in reply to the Office Action mailed *July 25, 2003*, which was made Final. Reconsideration and allowance of the subject application in view of the following remarks is respectfully requested.